Docket No.: 42P16768



N THE UNITED STATES PATENT AND TRADEMARK OFFICE

In Re the Application of:

HOK-KIN CHOI, ET AL.

Application No.: 10/609,443

Filed: June 26, 2003

For: PREPARATION OF ELECTROLESS

DEPOSITION SOLUTIONS

Art Group: Not yet assigned

Examiner: Not yet assigned

INFORMATION DISCLOSURE STATEMENT UNDER 37 C.F.R. §1.97

Commissioner for Patents P.O. Box 1450 Alexandria, VA 22313-1450

Sir:

In accordance with the duty of disclosure, enclosed is a copy of Information Disclosure Statement by Applicant (form PTO/SB/08), which is being submitted within three (3) months of filing of the application. It is respectfully requested that the cited references be considered and that the enclosed copy of PTO/SB/08 be initialed by the Examiner to indicate such consideration and a copy thereof returned to applicant(s). Copies of the references cited on PTO/SB/08 are enclosed herewith.

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The submission of this Information Disclosure Statement is not to be construed as a representation that a search has been made in the subject application and is not to be construed as an admission that the information cited in this statement is material to patentability.

Please charge any fees due to Deposit Account 02-2666. A duplicate copy of the Fee Transmittal (PTO/SB/17) is enclosed for this purpose.

Respectfully submitted,

BLAKELY, SOKOLOFF, TAYLOR & ZAFMAN LLP

Date: Aug. 12, 2003

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I hereby certify that this correspondence is being deposited with the United States Postal Service on the date shown below with sufficient postage as first class mail in an envelope addressed to: Mail Stop Commissioner Of Patents, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Krista Mathieson

Date

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Substitute for form 1449A/PTO

INFORMATION DISCLOSURE STATEMENT BY APPLICANT

Sheet 1 of 1

Complete If Kn wn		
Application Number	10/609,443	
Filing Date	June 26, 2003	
First Named Inventor	Hok-Kin Choi	
Art Unit	Not yet assigned	
Examiner Name	Not yet assigned	
Attorney Docket Number	42P16768	

	OTHER ART - NON PATENT LITERATURE DOCUMENTS		
Examiner Initials*	Cite No.1	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T²
		Watanabe and Honman, "Direct Elctroless Nickel Plating on Copper Circuits Using DMAB as a Second Reducing Agent" IEMT/IMC Proceedings; pgs 149- 153 (1998).	
		T. Osaka et al., "Preparation of CoB Soft Magnetic Thin Films by Electroless Plating" IEEE Translation Journal on Magnetics in JAPAN, Vol. 6, No. 1, January 1991. Pgs 85 - 40.	
	,	V.M. Dubin, "Selective electroless Ni deposition onto Pd-activated Si for integrated circuit fabrication", Thin Solid Films, 226 (1993) pgs 94-98.	
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Examiner	Date
Signature	Considered
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^{*}Examiner: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication.

^{&#}x27;Applicant's unique citation designation number, *Applicant is to place a check mark here if English language Translation is attached.